

Title (en)

PROCESS OF PREPARING AN ANISOTROPIC MULTILAYER USING PARTICLE BEAM ALIGNMENT

Title (de)

VERFAHREN ZUR HERSTELLUNG EINER ANISOTROPEN MEHRFACHSCHICHT DURCH PARTIKELSTRAHLAUSRICHTUNG

Title (fr)

PROCÉDÉ DE FABRICATION D'UN ÉLÉMENT MULTI COUCHES ANISOTROPIQUE A L'AIDE D'UN FAISCEAU À PARTICULES

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Application

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Abstract (en)

[origin: WO2010108593A1] The invention relates to a process of preparing a multilayer comprising two or more anisotropic layers with different optical axes by using a particle beam etching technique, to a multilayer obtained by said process, to the use of such a multilayer as optical compensator or retarder in optical and electrooptical devices, and to devices comprising such a multilayer.

IPC 8 full level

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Citation (search report)

See references of WO 2010108593A1

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